



চট্টগ্রাম প্রকৌশল ও প্রযুক্তি বিশ্ববিদ্যালয়  
CHITTAGONG UNIVERSITY OF ENGINEERING & TECHNOLOGY  
CHATTOGRAM-4349, BANGLADESH.

Memo No.-CUET/Reg./PF/T-376/1594

Date: 02 / 06 / 2024.

OFFICE ORDER

Dr. Yunus Ahmed, Associate Professor, Department of Chemistry, Chittagong University of Engineering & Technology (CUET), Chattogram is hereby permitted to participate in the '19<sup>th</sup> IWA Leading Edge Conference on Water and Wastewater Technologies' which will be held on 24-28 June at Essen, Germany. In this connection, ex-Bangladesh leave has been granted to him from 24/06/2024 to 29/06/2024 (including 24/06/2024 to 27/06/2024, ex-Bangladesh earn leave on full average pay). There is no financial involvement of this university in this regard.

He has to join this university on the expiry of leave as per usual practice. Otherwise, necessary action will be taken against the absentee as per the "Syndicate Decision-123/23".

By the approval of the Vice-Chancellor-

02/06/2024  
(Prof. Dr. Sheikh Muhammad Humayun Kabir)  
Registrar (Additional Charge)  
Chittagong University of Engineering & Technology.

Memo No.-CUET/Reg./PF/T-376/1594(10)

Date: 02 / 06 / 2024.

Copy forwarded for Information and necessary action to:

1. Dr. Yunus Ahmed, Associate Professor, Department of Chemistry, CUET, Chattogram.
2. Dean, Faculty of Science and Technology, CUET, Chattogram.
3. Director, IICT, CUET. (He is requested to upload this letter on the CUET website).
4. Head, Department of Chemistry, CUET, Chattogram. ✓
5. Comptroller, CUET, Chattogram.
6. Controller of Examinations, CUET, Chattogram.
7. Officer-in-Charge (Immigration), Shah Amanat International Airport, Chattogram/Hazrat Shahjalal International Airport, Dhaka, Bangladesh.
8. Deputy Director (Public Relation), CUET, for kind information of Vice-Chancellor, Chattogram.
9. Mrs. Minu Rani Barua, Section Officer, Registrar Office, CUET, Chattogram.
10. Guard/Personal/file.

21/5/2028  
(Naznin Akhter)

Deputy Registrar  
Registrar Office

Chittagong University of Engineering & Technology.